Guojin Chen

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Current Position

Visiting Student, *The University of Texas at Austin* 2023.08 – Present
Supervisor : Prof. David Z. Pan

Ph.D. Candidate, *The Chinese University of Hong Kong* 2021.08 – Present
Supervisor : Prof. Bei Yu

Education

Ph.D. in Computer Science, *The Chinese University of Hong Kong* 2021 – Present

M.S. in Computer Science, *The Chinese University of Hong Kong* 2019 – 2020

B.S. in Computer Science, *Huazhong University of Science and Technology* 2015 – 2019

Research Interests

- Design for manufacturing (DFM) / Electronic design automation (EDA)
- Computational lithography / Resolution enhancement technologies
- Deep Learning for VLSI / Physics-informed deep learning

Publications [Google Scholar; 91+ citations, h-index: 5+]

Representative publications that I am a primary author on are highlighted.

Conference papers

[C11] AlphaSyn: Logic Synthesis Optimization with Efficient Monte Carlo Tree Search
Zehua Pei, Fangzhou Liu, Zhuolun He, **Guojin Chen**, Haisheng Zheng, Keren Zhu, and Bei Yu
Proceedings of the 42th International Conference on Computer-Aided Design (**ICCAD 2023**)

[C10] Physics-Informed Optical Kernel Regression Using Complex-valued Neural Fields
Guojin Chen, Zehua Pei, Haoyu Yang, Yuzhe Ma, Bei Yu, and Martin Wong
ACM/IEEE Design Automation Conference (**DAC 2023**)

[C9] DiffPattern: Layout Pattern Generation via Discrete Diffusion
Zixiao Wang, Yunheng Shen, Wenqian Zhao, Yang Bai, **Guojin Chen**, Farzan Farnia, and Bei Yu
ACM/IEEE Design Automation Conference (**DAC 2023**)

[C8] GPU-accelerated Matrix Cover Algorithm for Multiple Patterning Layout Decomposition
Guojin Chen, Haoyu Yang, and Bei Yu
DTCO and Computational Patterning II (**SPIE 2023**)

[C7] Efficient Point Cloud Analysis Using Hilbert Curve.
Wanli Chen, Xinge Zhu, **Guojin Chen**, and Bei Yu
European Conference on Computer Vision (**ECCV 2022**)

[C6] AdaOPC: A Self-Adaptive Mask Optimization Framework For Real Design Patterns
Wenqian Zhao, Xufeng Yao, Ziyang Yu, **Guojin Chen**, Yuzhe Ma, Bei Yu, and Martin Wong
Proceedings of the 41th International Conference on Computer-Aided Design (**ICCAD 2022**)

[C5] LayouTransformer: Generating Layout Patterns with Transformer via Sequential Pattern Modeling
Liangjian Wen, Yi Zhu, Lei Ye, **Guojin Chen**, Bei Yu, Jianzhuang Liu, and Chunjing Xu
Proceedings of the 41th International Conference on Computer-Aided Design (**ICCAD 2022**)

[C4] DevelSet: Deep Neural Level Set for Instant Mask optimization
Guojin Chen, Ziyang Yu, Hongduo Liu, Yuzhe Ma, and Bei Yu
Proceedings of the 40th International Conference on Computer-Aided Design (**ICCAD 2021**)

[C3] Learning Point Clouds in EDA.
Wei Li, **Guojin Chen**, Haoyu Yang, Ran Chen, and Bei Yu
ACM International Symposium on Physical Design (**ISPD 2021**)

[C2] DAMO: Deep Agile Mask Optimization for Full Chip Scale
Guojin Chen, Wanli Chen, Yuzhe Ma, Haoyu Yang, and Bei Yu
Proceedings of the 39th International Conference on Computer-Aided Design (**ICCAD 2020**)

[C1] A GPU-enabled Level Set Method for Mask Optimization
Ziyang Yu, **Guojin Chen**, Yuzhe Ma, and Bei Yu
IEEE/ACM Proceedings Design, Automation and Test in Europe (**DATE 2020**)

Journal papers

[J4] L2O-ILT: Learning to Optimize Inverse Lithography Techniques
Binwu Zhu, Su Zheng, Ziyang Yu, **Guojin Chen**, Yuzhe Ma, Fan Yang, Bei Yu, and Martin Wong
IEEE Transactions on Computer-Aided Design of Integrated Circuits and Systems (**TCAD 2023**)

[J3] A GPU-Enabled Level-Set Method for Mask Optimization
Ziyang Yu, **Guojin Chen**, Yuzhe Ma, and Bei Yu
IEEE Transactions on Computer-Aided Design of Integrated Circuits and Systems (**TCAD 2023**)

[J2] DevelSet: Deep Neural Level Set for Instant Mask optimization
Guojin Chen, Ziyang Yu, Hongduo Liu, Yuzhe Ma, and Bei Yu
IEEE Transactions on Computer-Aided Design of Integrated Circuits and Systems (**TCAD 2023**)

[J1] DAMO: Deep Agile Mask Optimization for Full-Chip Scale
Guojin Chen, Wanli Chen, Qi Sun, Yuzhe Ma, Haoyu Yang, and Bei Yu
IEEE Transactions on Computer-Aided Design of Integrated Circuits and Systems (**TCAD 2022**)

Open Source Repositories

1. OpenOPC/OpenILT — ★32 — *Open-source inverse lithography technology (ILT) framework* 2023
2. ai4eda/awesome-AI4EDA — ★67 — *A curated paper list of existing AI for EDA studies.* 2023

Experiences

Research Assistant, *The Chinese University of Hong Kong* 2020 – 2021
Research Intern, *Tencent* 2018 – 2019

Awards

Ph.D. Studentship 2021 – 2025
By Chinese University of Hong Kong, 2021-2025
Outstanding Graduate 2019
By Huazhong University of Science and Technology

Professional Activities

Paper Review / External Review

Design Automation Conference (DAC) 2021-2023
AAAI Conference on Artificial Intelligence (AAAI) 2022-2023
IEEE Transactions on Computer-Aided Design of Integrated Circuits and Systems (TCAD) 2022-2023

Teaching

Python Computing (AIST 1110), TA F2022
Mobile Computing (CSCI 3310), TA S2022
Numerical Optimization (AIST 3010), TA F2021